	Type	L #	Hits	Search Text	DBs
1	IS&R	L1	1	("6682982").PN.	US- PGPU B; USPA T
2	BRS	L2	1	•	US- PGPU B; USPA T
3	IS&R	L3	1	("6420226").PN.	US- PGPU B; USPA T
4	BRS	L4	0	3 and gate	US- PGPU B; USPA T
5	IS&R	L5	0		US- PGPU B; USPA T
6	IS&R	L6	1		US- PGPU B; USPA T

	Type	L#	Hits	Search Text	DBs
7	BRS	L7	1	6 and gate	US- PGPU B; USPA T
8	BRS	L8	15217	transfer adj2 gate	US- PGPU B; USPA T
9	BRS	L9	28793	trench adj2 (isolation or isolate	US- PGPU B; USPA T
10	BRS	L10	199	8 same 9	US- PGPU B; USPA T
11	BRS	L11	33316		US- PGPU B; USPA T
12	BRS	L12	4		US- PGPU B; USPA T

	Type	L #	Hits	Search Text	DBs
13	BRS	L13	947	8 and 9	US- PGPU B; USPA T
14	BRS	L14	228	13 and 11	US- PGPU B; USPA T
15	BRS	L15	33412	capacitor adj2 (electrode or plate)	US- PGPU B; USPA T
16	BRS	L16	105	14 and 15	US- PGPU B; USPA T
17	BRS	L17	0	("2005/0230764").URPN.	USPA T
18	BRS	L18	35350	(reduced or reduce or reduction or reducing) near2 height	US- PGPU B; USPA ⁻ T

	Type	L#	Hits	Search Text	DBs
19	BRS	L19	29	9 near10 18	US- PGPU B; USPA T
20	BRS	L20	19864	(reduced or reduce or reduction or reducing) near2 height	USOC R; FPRS; EPO; JPO; DERW ENT; IBM_T DB
21	BRS	L21	8337	trench adj2 (isolation or isolating isolated or isolate or insulator or insulation or insulating)	USOC R; FPRS; EPO; JPO; DERW ENT; IBM_T DB

	Type	L #	Hits	Search Text	DBs
22	BRS	L22	23	20 and 21	USOC R; FPRS; EPO; JPO; DERW ENT; IBM_T DB